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| APPLICATION NO.   | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO.   | CONFIRMATION NO. |
|---|-------------|----------------------|-----------------------|------------------|
| 09/874,313  | 06/06/2001  | Shingo Ishimaru      | Q64849                | 6162             |
| 7590 11/22/2004 SUGHRUE, MION, ZINN, MACPEAK & SEAS, PLLC 2100 Pennsylvania Avenue, N.W. Washington, DC 20037 |             |                      | EXAMINER              |                  |
|   |             |                      | ANGEBRANNDT, MARTIN J |                  |
|   |             |                      | ART UNIT              | PAPER NUMBER     |
|   |             |                      | 1756                  |                  |

DATE MAILED: 11/22/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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|   | Application No.   | Applicant(s)   |  |  |  |
|---|---|--|--|--|--|
|   | 09/874,313  | ISHIMARU ET AL.  |  |  |  |
| Office Action Summary   | Examiner  | Art Unit   |  |  |  |
|   | Martin J Angebranndt  | 1756   |  |  |  |
| The MAILING DATE of this communication app Period for Reply   | ears on the cover sheet with the  | e correspondence address   |  |  |  |
| A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). | within the statutory minimum of thirty (30) dill apply and will expire SIX (6) MONTHS fro           | timely filed  ays will be considered timely.  In the mailing date of this communication. |  |  |  |
| Status  |   |  |  |  |  |
| 1) Responsive to communication(s) filed on 07 Se  | eptember 2004.  |  |  |  |  |
| 2a) This action is <b>FINAL</b> . 2b) This  | action is non-final.  |  |  |  |  |
| 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is  |   |  |  |  |  |
| closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.   |   |  |  |  |  |
| Disposition of Claims   |   |  |  |  |  |
| 4)  Claim(s) 1-3 and 5-13 is/are pending in the app 4a) Of the above claim(s) is/are withdraw 5)  Claim(s) is/are allowed. 6)  Claim(s) 1-3 and 5-13 is/are rejected. 7)  Claim(s) is/are objected to. 8)  Claim(s) are subject to restriction and/or   | n from consideration.   |  |  |  |  |
| Application Papers  |   |  |  |  |  |
| 9) The specification is objected to by the Examiner.  |   |  |  |  |  |
| 10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.   |   |  |  |  |  |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).   |   |  |  |  |  |
| Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.  |   |  |  |  |  |
| Priority under 35 U.S.C. § 119  | on the altaened emet  | Action of 101111 PTO-152.  |  |  |  |
| 12) Acknowledgment is made of a claim for foreign p a) All b) Some * c) None of:  1. Certified copies of the priority documents if 2. Certified copies of the priority documents if 3. Copies of the certified copies of the priority application from the International Bureau ( * See the attached detailed Office action for a list of   | have been received. have been received in Applicat y documents have been receive PCT Rule 17.2(a)). | ion No<br>ed in this National Stage  |  |  |  |
| Attachment(s)   |   |  |  |  |  |
| 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date  | 4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:                          | (PTO-413)<br>ate<br>atent Application (PTO-152)  |  |  |  |

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1. The response provided by the applicant has been read and given careful consideration. Response to the argument made by the applicant are presented after the first rejection to which they are directed. Rejections of the previous office action not repeated below are withdrawn in view of the amendment to the claims.

- The following is a quotation of the second paragraph of 35 U.S.C. 112:
   The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 2. Claims 1-3 and 5-13 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In step (1) of claim 1, the use of elements of group 2B is recited, but they are not recited in the most recently added text.

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1,3 and 5-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ichihara et al. '756, in view of Ito JP 62-270386 and Iida et al. '961, further in view of Murray et al., "Synthesis and Charachtorization of nearly monodisperse CdE ...."., J. Am. Chem. Soc., Vol. 115(19) pp. 8706-8715 and JP 62-125550.

Ichihara et al. '756 teaches phase change optical recording materials where the phase change materials are particles dispersed in a matrix, such as a polymeric resin. (6/13-46) The

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size of the particles may be 1-20 nm. (6/2). Other phase change recording materials, including AgInSbTe and InSeTlCo, are disclosed. (4/9-14).

Ito JP 62-270386 teaches powdered or particulate optical recording material dispersed with a organic substance to prevent flocculation/precipitation and an organic resin. Useful particulate materials include phase change recording materials such as GeTe, GaTeSe, PbTeSe, TeO<sub>X</sub>GeSn and others. (page 2/bottom left column) The chemical formula of the dispersant is disclosed in the examples.

lida et al. '961 teach dispersal of semiconductor particles of 0.1 to 50 nm, preferably 0.5 to 30 nm in a matrix of an organic polymer or inorganic glass material. (3/9-20). Useful semiconductor materials include CdS, CdSe, CdSSe and CdTe. (2/58-66). When preparing the embodiments using a resin matrix a solution of the semiconductor particles is mixed with the resin solution and spin coated. (3/47-41). The laser used is between 310 and 890 nm. (4/1-5) The use of protective dielectric layers between the shutter layer and the substrate and/or the reflective layer is disclosed.

Murray et al., "Synthesis and Charachtorization of nearly monodisperse CdE ...."., J. Am. Chem. Soc., Vol. 115(19) pp. 8706-8715 teach methods for producing CdS, CdSE and CdTe sols of fine particles having diameters of 1.2 to 11.5 nm. (abstract). Trioctylphosphines of Te and SE were prepared and mixed with dimethylcadmium with stirring and heating at 230-260 degrees. These are isolated and purified by cooling to 60 degrees C and adding methanol to flocculate the crystals, followed by centrifugal separation. The flocculant is then re-dispersed in butanol to form a clear solution, solids removed, methanol added to remove the excess TOP and TOPO, followed by re-dispersion. The CdSe nanocrystallites can be re-dispersed in a variety of

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solvents including alkanes, (hexane page 8707, upper right column), aromatics, long chain alcohols, chlorinated solvents, and organic bases (amines, pyridines, furans, phosphines). (page 8707/lower left column) The CdSe nanocrystallites are disclosed as being stabilized (from agglomeration) by a coating of alkyl groups anchored to the surface by phosphineoxide/chalcogenide moeities. (pages 8708, bottom left to top right columns)

It would have been obvious to one skilled in the art to modify the process of Ichihara et al. '756 by coating the 1-20 nm AgInSbTe or InSeTlCo phase change recording media particles using the process of Ito JP 62-270386 to disperse them into the resin to remove the need for a sputtering step with the apparatus and time involved and replace it with a spin coating process including the resin and the stabilized particles as this is less equipment intensive and cheaper with a reasonable expectation of success based upon the disclosure of Iida et al. '961 that within the optical recording media art, it is known to disperse particles into polymeric matrices in this manner and further in addition to the basis provided above, the examiner holds that it would have been obvious to modify the combination of Ichihara et al. '756 with Ito JP 62-270386 and Iida et al. '961 by an analogeous process to that of Murray et al., "Synthesis and Charachtorization of nearly monodisperse CdE ...."., J. Am. Chem. Soc., Vol. 115(19) pp. 8706-8715 to prepare the colloidal/particulate phase change materials with a reasonable expectation of success based upon the disclosure that trioctylphosphine prevents flocculation as does the dispersant in the Ito JP 62-270386 reference and the known use of solgel/wet processing techniques in forming phase change recording layers as evidenced by JP 62-125550.

The basis of the obviousness is direct to the dispersion of the recording layer in a polymer film no the dielectric film. The applicant's arguments ignore the teachings of the use of

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polymeric matrices rather than the inorganic matrices at 4/15-25 and table 3 and the direction of the teachings of the references to toward sol-gel processes. The rejection stands.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J Angebranndt whose telephone number is 571-272-1378. The examiner can normally be reached on Monday-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9309 for regular communications and 703-872-9309 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703/308-0661.

Martin J Angebranndt Primary Examiner Art Unit 1756

November 19, 2004